Multiple Exponence of Derivational Morphology in Rarámuri (Tarahumara)*

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1. Background
Theories of structural complexity and blocking (Anderson 1992, Andrews 1990) are challenged by the existence of Multiple Exponence (ME), a one-to-many mapping between a (morphological) category and its formal expression (Matthews 1972). Cases of ME, however, are well attested (e.g. agreement in Potawatomi (Anderson 1992), negation in Luganda (Peterson 1994), negation and agreement in Limbu (van Driem 1997)), and have been argued to support realizational theories of morphology and syntax. In these theories, morphosyntactic features are transferred and realized morphologically in several ways in the language (Matthews 1972, Stump 2001, Sells 2004); this entails that ME might be exhibited by inflectional categories, but not by categories that do not involve transfer of morphosyntactic features, such as argument structure changing operations.

Given the recursivity property of derivational morphology (Booij 2000), a derivational process may apply to a stem previously derived through the same process. In Rarámuri (Tarahumara), a causative stem may be causativized a second time, adding a second causer argument, as shown in (1b):1

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1 Abbreviations: A - Accusative; APPL – Applicative; CAUS – Causative; CAUS.IND - Indirect Causative; COP – Copula; COMP – Complementizer; DEM – Demonstrative; DESID – Desiderative; DUB – Dubitative; EV - Evidential; FUT.SG - Future sg; FUT.PL - Future Pl; FUT.PASS - Future Passive; HAB.PASS – Habitual Passive; INCH – Inchoative; INT – Intensive; MOT - Associated
Gabriela Caballero

(1) a. ne mi biné -ri -ma wikará
1SG 2SGA LEARN -CAUS -FUT.SG SING
‘I will make you learn (I’ll teach you) how to sing’
[[[learn] + CAUS = teach]

b. nihé mi biné -r -ti -ki kúruwi
1SG 2SGA LEARN -CAUS -CAUS -PST:1 CHILDREN
‘I made you teach the children’
[[[learn] + CAUS = teach] + CAUS = make teach]

However, Rarámuri also displays multiple formal instances of the same derivational process with no parallel semantic recursivity, as shown in (2).

(2) nihé mi rikú -r -ti -ma
1SG 2SGA GET.DRUNK -CAUS -CAUS -FUT.SG
‘I will make you get drunk’ (*‘I will make you make her drunk’)

The example in (2) constitutes ME, since a single morphological category (one causer argument) is formally introduced by two exponents (two causative allomorphs).

This paper makes an empirical contribution by introducing several patterns of ME in Rarámuri, which crucially involve derivational information. This paper also shows that ME in Rarámuri targets categories in specific areas of the layered structure of the verb with characteristic morpho-prosodic properties which make them difficult to parse and prone to be reanalyzed as part of the stem. Specifically, I argue that the opaque inner morphological markers generate a morphological constituent that requires further affixation.

2. **Rarámuri Verb Structure**

Rarámuri is an agglutinative, mostly suffixing Uto-Aztecan language spoken in the Mexican State of Chihuahua by about 75,000 speakers. Figure 1 shows the relative order of the suffixes of the Rarámuri verb. The “inner stem” is the input to suffixation, where lexicalized and unproductive or semi-productive processes take place.

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Motion; N – Nominative; PARTC – Participle; PRES – Present; PST – Past; PST:1 - Past 1st person; TR – Transitive; TR.PL – Transitive Pluractional.

2 There are no case markers in this language and there is no pronominal form for third person.

3 The characterization of Rarámuri’s suffixes as derivational or inflectional was based on criteria such as generality/productivity, obligatoriness, recursivity and sensitivity to grammatical environment (Bybee 1985, Bickel & Nichols 2001).

4 This paper presents data of the Rarámuri dialect spoken in Choguita, municipality of Guachochi. The data were obtained through my field research in this community from 2003 to 2007.

5 Ordering facts that partially motivate this organization are shown in the Appendix.
Multiple exponence of derivational morphology in Rarámuri (Tarahumara)

Figure 1 – Suffix positions and categories expressed in the Rarámuri verb
[Inner stem] S1  S2  S3  S4  S5  S6  S7  S8  S9  S10  S11
INCH  TR  APPL MT  CAUS  APPL  DESID  EV  TAM  TAM  Subord.

This scheme does not imply a slot-and-filler, template-like structure. The verb has a layered, hierarchical structure that can be divided into stem levels, determined by morphophonological properties, such as back harmony and stress shifts. The morphological processes taking place closer to the root are tighter phonologically to the root than later morphological process. This is schematized in Figure 2.

Figure 2 – Rarámuri verbal stem levels and their morphophonology

<table>
<thead>
<tr>
<th>Stem levels</th>
<th>Inner Stem</th>
<th>Derived Stem</th>
<th>Syntactic Stem</th>
<th>Finite Verb</th>
<th>Subord. Verb</th>
</tr>
</thead>
<tbody>
<tr>
<td>Morphophonological processes</td>
<td>Compensatory lengthening</td>
<td>Stress shift</td>
<td>Back harmony</td>
<td></td>
<td></td>
</tr>
</tbody>
</table>

Stress is assigned in either the first, second or third syllable, on either the root or on suffixes that are cohering prosodically with the stem (there is an initial three-syllable stress window (Caballero 2005)). The stress behavior of suffixes is schematized in Figure 3:

Figure 3 – Rarámuri verbal stem levels and stress behavior of suffixes
[[[Inner Stem] S1  S2  Derived] S3  S4  S5  S6  Syntactic] S7  S8  S9  S10  Finite]  S11  Sub.]

Cohering  Non-Cohering  Cohering  Non-Cohering

The syntactic stem (S3-S6) constitutes an intermediate zone: it is the domain of only one phonological process (back harmony), its suffixes are non-cohering, and causative –ti and applicative –ki (in S5 and S6) display ME, as it will be discussed in §3.3 and §3.4.

3. Multiple Exponents in the Rarámuri Verb
ME in this language is formally expressed in several ways:

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6 Similar patterns are documented for a closely related language, Highland Guarijío (Miller 1996).
a) Prefixation and stem consonant mutation to mark intensive aspect (§3.1).

b) Applicative stems that redundantly take applicative suffixes (§3.2).

c) Multiple suffixation of causative and applicative suffixes with no parallel semantic recursivity (§3.3 and §3.4).

Though patterns (a) and (b) are not uncommon cross-linguistically, to my knowledge there are only a few documented cases of pattern (c) for derivational morphology.\(^7\)

### 3.1. Prefixation and Medial Consonant Mutation in the Intensive

Rarámuri “intensives” (pluractionals) indicate in the verb a plural subject, or an action that occurs or is being performed by several agents or by the same agent several times (Lionnet 1968). Intensives, appearing frequently in text but of receding productivity, are marked through prefixation (a), consonant mutation (b), or marked through both prefixation and consonant mutation (c-d).\(^8\)

\[(3)\]

<table>
<thead>
<tr>
<th></th>
<th>Intensive</th>
<th></th>
</tr>
</thead>
<tbody>
<tr>
<td>a</td>
<td>čóni</td>
<td>o-čóni</td>
</tr>
<tr>
<td>b</td>
<td>kapórame</td>
<td>kabórame</td>
</tr>
<tr>
<td>c</td>
<td>kípá</td>
<td>i-kíbá</td>
</tr>
<tr>
<td>d</td>
<td>bahí</td>
<td>a-pahí</td>
</tr>
</tbody>
</table>

The forms with both prefixation and consonant mutation do not have alternative forms with a single exponent for the intensive.

### 3.2. Applicative Stems Adding Applicative Suffixes

Another ME pattern involves applicative stems. There are unaccented and accented roots and stress-perturbing and stress-neutral suffixes in Rarámuri. Stress-perturbing suffixes trigger stress shifts and vowel alternations with unaccented stems. Unaccented stems have a valence stem allomorphy system (schematized in Table 4): applicative stems are formed by replacing the final stem vowel with a stressed front vowel (e.g., (4c)).

<table>
<thead>
<tr>
<th>Table 4 – Valence stem allomorphy</th>
</tr>
</thead>
<tbody>
<tr>
<td><strong>Intransitive</strong></td>
</tr>
<tr>
<td>-</td>
</tr>
<tr>
<td>-</td>
</tr>
<tr>
<td>noko/noká</td>
</tr>
<tr>
<td>suwí</td>
</tr>
</tbody>
</table>

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\(^7\) Similar cases are found in Bantu (e.g., causative doubling in Jita (Downing 2005), Kinande (Mutaka and Hyman 1990), and Bemba (Hyman 1994)).

\(^8\) The prefix (originally \(i\)-) assimilates in color with the first stem vowel (Lionnet 1968).
Multiple exponence of derivational morphology in Rarámuri (Tarahumara)

(4) a. nihé ba’áří iči –méa muni
1SGN TOMORROW PLANT -FUT.SG BEANS
‘I will plant beans tomorrow’

b. nihé sunú ičá –ki rapáko
1SGN CORN PLANT -PST:1 YESTERDAY
‘I planted corn yesterday’

c. nihé ba’áří ne yé –ra iči –ma
1SGN TOMORROW 1SGN MOTHER-POSS PLANT.APPL-FUT.SG
‘I will plant for my mom tomorrow’

These applicative stems might add an applicative suffix in an apparently redundant fashion (e.g. (5b-6b)).

(5) a. nihé ba’áří ne yé –ra iči –ma
1SGN TOMORROW 1SGN MOTHER-POSS PLANT.APPL-FUT.SG
‘I will plant for my mom tomorrow’

b. nihé ne yé –ra iči –ki –ma
1SGN 1SGN MOTHER-POSS PLANT.APPL -APPL -FUT.SG
‘I will plant for my mom’

(6) a. ma =ni mi suwé –ri remé
ALREADY=1SGN 2SGA FINISH.UP.APPL-PST TORTILLAS
‘I already finished (ate) up your tortillas’

b. ma =ni mi suwé –ki –ri remé
ALREADY=1SGN 2SGA FINISH.UP.APPL-APPL -PST TORTILLAS
‘I already finished (ate) up your tortillas’

There is free variation between the verbal forms that have one applicative marker (5a, 6a) and the forms with two applicative markers (5b, 6b).

3.3. Multiple Affixation of Causative

The Rarámuri causative suffix adds a causer argument to both intransitive and transitive verbs. The causative suffix has two allomorphs, -ti (7a) and –ri (7b).9

The distribution of the allomorphs is largely unpredictable, but following general rules of allophony in the language, the allomorph with the voiceless onset (–ti) is used post-consonantally. In (7c) post-tonic vowel deletion yields an environment in which the onset of the causative is voiceless.

9 All suffixes with a stop onset display this allomorphy.
(7) a. ne mi napá -ti -ma ta múchi
   1SGN 2SGA HUG -CAUS -FUT.SG DEM BABY
   ‘I will make you hug the baby’

b. ne mi pewá -ri -ma bahi -wa -chi
   1SGN 2SGA SMOKE -CAUS -FUT.SG DRINK -HAB.PASS -LOC
   ‘I will make you smoke at the drinking party’

c. ti michípiri tamí láan -ti -ki *lán-ri-ki
   /ti michípiri tami láni -ti -ki
   DEM SPLINTER 1SGA BLEED -CAUS -PST
   ‘the splinter made me bleed’

A very productive pattern of ME in Rarámuri involves repetition of the causative suffix, where post-tonic vowel deletion yields non-identical allomorphs of the causative suffix, as shown in (8).\(^{10}\)

(8) á =mi tamí mé -r -ti -ma?
   AFF =2SGN 1SGA WIN -CAUS -CAUS -FUT.SG
   ‘will you make me win?’

The possibility of having ME of the causative is conditioned by the position of stress and post-tonic vowel deletion. There are stems that have final or pre-final stem stress depending on tense/aspect morphemes or alternating freely. On these stems, non-final stem stress yields a form with one causative (9a), while final stem stress yields a form with ME (9b).

(9) a. tamí ūb -ti -ma, mama?
   1SGA BATH -CAUS -FUT.SG MOM
   ‘Will you bathe me, mom?’

b. tamí ma ubá -r -ti -ri ne ye -ra
   1SGN ALREADY BATH -CAUS -CAUS-PST 1SGN MOM-POSS
   ‘my mom already bathed me’

The distribution of ME of causatives is consistent with this prosodic generalization: final-stress stems will optionally have ME of the causative (10-11). The forms with one causative freely alternate with forms with two causatives.

(10) a. ne mi mé -r -ma orá
   1SGN 2SGA WIN -CAUS -FUT.SG EV
   ‘I will make you win’

\(^{10}\) Recall that the two allomorphs are also used with compositional semantics (cf. (1b))
Multiple exopnence of derivational morphology in Rarámuri (Tarahumara)

b. ne mi mé -r -ti -ma orá
   1SGN 2SGA WIN -CAUS -CAUS -FUT.SG Ev
   ‘I will make you win’

(11) a. muhé ma tamí haré wási ko’í -ri -ri
   1SGN ALREADY 2SGA SOME COWS KILL -CAUS -PST
   ‘You already made me kill some cows’

b. ne mi haré wási ko’í -r -ti -ma orá
   1SGN 2SGA SOME COWS KILL.PL -CAUS -CAUS-FUT.SG Cer
   ‘I will make you kill some cows’

Stems with non-final stress, on the other hand, where post-tonic vowel deletion targets the final vowel of the stem, never display double causative suffixation, as in the examples in (12).

(12) a. nihé émi ték -ti -ma *ték-r-ti-ma
   /nihé émi téki -ti -ma/
   1SGN 2PLA BE.DRUNK.PL -CAUS -FUT.SG
   ‘I will make you all drunk’

b. nihé mi paník -ti -ma *paník-r-ti-ma
   /nihé mi paníkki -ti -ma/
   1SGN 2SGA WASH.HANDS -CAUS -FUT.SG
   ‘I will make you wash your hands’

3.4. Multiple Suffixation of Applicative
The applicative suffix -ki adds a benefactive argument (‘to do X for Y’), and, as the causative suffix, it can be doubled with no equivalent semantic compositionality (13-14). The forms with one and two applicatives are judged to be semantically equivalent.

(13) a. ne mi semé -ki -ma orá biré takí
   1SGN 2SGA PLAY -APPL -FUT.SG Ev ONE SONG
   ‘I will play one song for you’

b. ne mi semé -ki -ki -ma orá biré takí
   1SGN 2SGA PLAY -APPL -APPL -FUT.SG Ev ONE SONG
   ‘I will play one song for you’

(14) a. ne mi wató -n -ki -ma úle
   1SGN 2SGA STRETCH -Tr -APPL -FUT.SG RUBBER
   ‘I will stretch out the rubber for you’
Unlike ME of causatives, ME of applicative -ki is not prosodically conditioned, and is very restricted and subject to considerable speaker variation.

There are, however, other, less restricted patterns of ME involving applicatives in Rarámuri. Suffixes –ni and –si introduce benefactive arguments, but are less general and productive than suffix -ki. Verbs taking suffixes –ni (15) and –si (16) can add the more productive suffix -ki:

(15) a. ne mi sú -n -ma sipúcha 1sgN 2sgA SEW -APPL -FUT.SG SKIRT
‘I will sew a skirt for you’

b. ne mi sú -n -ki -ma sipúcha 1sgN 2sgA SEW -APPL -APPL -FUT.SG SKIRT
‘I will sew a skirt for you’

(16) a. ma =ni mi pá -si -ri pelota ALREADY=1sgN 2sgA THROW -APPL -PST BALL
‘I already threw the ball at you’

b. ma =ni mi pá -si -ki -ri pelota ALREADY=1sgN 2sgA THROW -APPL -APPL -PST BALL
‘I already threw the ball at you’

The examples in (16-17) show that in these cases there is also free variation between the forms with one and two applicative suffixes.

4. ME as Morphological Transparency

There are, then, several patterns of ME in Rarámuri that involve derivational information (intensive, causative and applicative). What should be accounted for is the fact that ME is restricted to the inner stem and the syntactic stem:

Figure 4 – Rarámuri verbal stem levels and the occurrence of ME

<table>
<thead>
<tr>
<th>Inner stem</th>
<th>Derived stem</th>
<th>Syntactic stem</th>
<th>Finite verb</th>
<th>Subord.</th>
</tr>
</thead>
<tbody>
<tr>
<td>S1 S2</td>
<td>S3 S4</td>
<td>S5 S6</td>
<td>S7 S8 S9 S10</td>
<td>S11</td>
</tr>
<tr>
<td>ME</td>
<td>ME</td>
<td>ME</td>
<td>ME</td>
<td>ME</td>
</tr>
</tbody>
</table>

What these specific areas of the verb have in common is that the morphological markers that belong in these zones are difficult to parse. According to Hay & Plag (2004), affixes have different degrees of decomposability or parsability in speech perception, and occupy a place along a processing complexity scale. On this account, affixes difficult to parse are less separable affixes with higher
boundary strengths, either because they are less phonologically segmentable, less transparent, less frequent and/or less productive (2004:571).

The morphological markers exhibiting ME in Rarámuri are difficult to parse in two ways: they are either increasingly unproductive (intensive and applicative) or less phonologically segmentable due to a high degree of morphophonological fusion (causative). Thus, the overarching mechanism generating ME in the Rarámuri verb is morphological opacity: ME arises when a morphological marker is difficult to parse and a second round of marking is required for the sake of morphological transparency.

ME in the syntactic stem, a verbal zone with non-cohering suffixes, is prosodically conditioned. As shown in §3.3, ME of the causative suffix depends on stress assignment and post-tonic vowel deletion. Post-tonic vowel deletion targets the nucleus of the causative suffix, making this suffix less phonologically segmentable. Specifically, the inner copy of the causative is getting fused phonologically and reanalyzed as part of the stem; the outer copy is there for morphological transparency. This is shown schematically in Figure 5.

**Figure 5 – Reanalysis of causative allomorph**

<table>
<thead>
<tr>
<th>Post-tonic V deletion:</th>
<th>Reanalysis and further suffixation:</th>
</tr>
</thead>
<tbody>
<tr>
<td>mē-ri-ma</td>
<td>mē-r-ma - mē-r-ti-ma</td>
</tr>
</tbody>
</table>

The first copy of the causative, reanalyzed as part of the stem, generates a Causative Stem, a morphological constituent that requires further suffixation.

Doubling of applicative suffix –ki, on the other hand, seems to arise through analogical extension with the causative. In this case analogical extension is plausible, given the morpho-syntactically relatedness of causative and applicative, and the adjacency of these suffixes in the layered structure of the verb.

Finally, the remaining cases of ME can also be thought of as arising from morphological opacity. In these cases, ME targets categories that are less parsable due to their decreasing productivity. The intensive pattern, which involves prefixation and consonant mutation, is archaic and has been argued to originate in a formerly productive stress pattern with voiceless/fortis onsets of stressed syllables (Lionnet 1972). The applicative patterns, however, are a more recent development: both the applicative stems with vowel alternations and the roots that take the less general applicative suffixes are re-interpreted as requiring the further affixation of the more productive and general applicative suffix –ki. There are no

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11 The reduplicated forms would have a plosive voicing pattern opposite to that of unreduplicated stems. The loss of the rhythmic pattern, plus leveling of the stress differences between unreduplicated and reduplicated stems, would have then rendered the voicing alternation opaque.
cases of applicative stems that add the less general suffixes –ni and -si. Only the more productive applicative -ki can be attached to an applicative stem.

Since forms displaying ME co-exist freely with forms with no ME, we might consider this phenomenon as a first step in a historical process that has been proposed as the source of ME in Skou (Donahue 1999). In Skou, a language of New Guinea, a series of sound changes (loss of voicing and other contrasts) led to consonant cluster simplifications. These changes affected agreement prefixes, leading to loss of contrast in a large number of verb forms in paradigms. “These factors would appear to be sufficient to bring about a second process of cliticization onto the verb in order to preserve contrastive verbal agreement” (Donohue 2003:493). Similar developments have been proposed for the ME patterns of Limbu, a Kiranti language (van Driem 1997, Anderson 2001).

5. Some Possible Implications

This case raises the more general issue of the status of derivational morphology for realizational models of morphology, which are founded on the assumption that inflection and derivation belong to different components of the grammar, and thus differ in their formal properties (the ‘Split Morphology Hypothesis’ (Matthews 1972, Anderson 1992). ME is commonly described for inflection (particularly agreement), but not for derivation. This paper shows that ME can be morphologically conditioned and not constrained to inflection, constituting a possible example of how inflectional and derivational morphology do not differ drastically as to their formal morphological properties.

References


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12 In Guarijío, a closely related language, an applicative stem might co-occur with the applicative suffix –nie (cognate to Rarámuri applicative -ni): čuhč-é-nie-na (LOAD-APPL-APPL-PRES) ‘to load (something) over a beast’ (Miller 1996:162)

13 In contrast with other dialects of Rarámuri (cf. Caballero 2003), the variant spoken in Choguita is also innovating the replacement of some causative suffixes exclusive to predicates of change of state with the more general causative suffix –ti.


Appendix: Ordering facts of the Rarámuri verb

INCH (S1) – TR.PL (S2)
nehé rata -bá -ča -ma ko’wá -ami
1SGN HEAT -INCH -TR.PL-FUT.SG EAT -PRTC
‘I will heat up the food’

TR (S2) – APPL (S3)
ne mi moo -bú -ni -ma ta towí trókači
1SGN 2SGA GO.UP -TR -APPL -FUT.SG DEM BOY TRUCK
‘I will lift you the boy up into the truck’

APPL (S3) – MOT (S4)
nám -ta hu nápu ma tamí širú -n -ši -o
HEAR -PARTC COP COMP ALREADY 1SGA HUNT -APPL -MOT -Ev
‘It sounds like (they) are already hunting it for me’

MOT (S4) – CAUS (S5)
mi =ni wíkará -si -ti -ma orá sumá bu’uchí
2SGA =1SGN SING -MOT -CAUS -FUT.SG EV ALL ROAD
‘I will make you go singing all the way’

CAUS (S5) – APPL (S6)
mi =n Patricio soda rarii -r -ti -ki -ma orá
2SGA =1SGN SODA BUY -CAUS -CAUS -APPL -FUT.SG EV
‘I will make you buy soda for Patricio’

APPL (S6) – DESID (S7)
ne mi biré wási mi’rí -ki -niri muhé omáwarachi
1SGN 2SGA ONE COW KILL -APPL -DESID 2GNN PARTY
‘I want to kill one cow for you, for your party’

DESID (S7) – EV (S8)
ne ko mayé ma bahí -ni -čin -o
1SGN EMPH THINK ALREADY DRINK -DESID-EV -Ev
‘I think it sounds like they already want to drink (start the drinking party)’